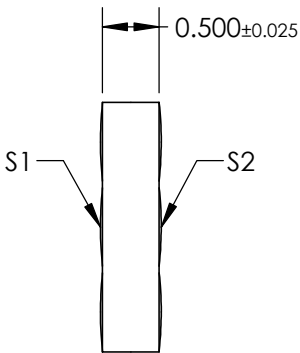
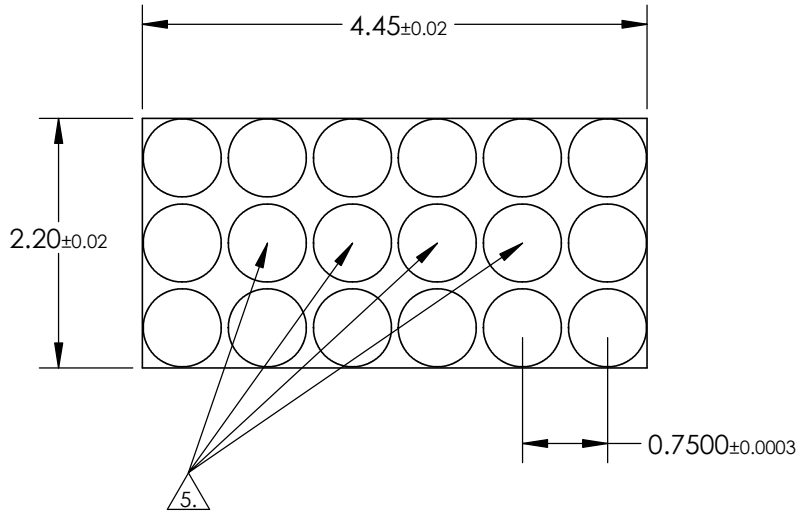
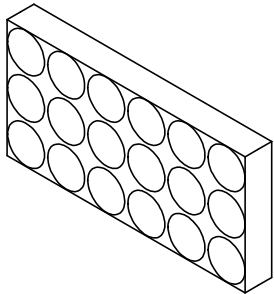



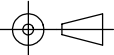
NOTES:

- 1. SUBSTRATE:  
Silicon
- 2. COATING (APPLY ACROSS COATING APERTURE):  
S1 & S2: R(AVG) ≤0.5% @ 1250 - 1620
- 3. WORKING DISTANCE (mm):  
1.1143
- 4. MODE FIELD DIAMETER (mm):  
Source: 0.0104  
Target: 0.25
- 5. ACTIVE LENSES CENTERED ON SUBSTRATE
- 6. ROHS: COMPLIANT



SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE  
DIMENSIONS ARE FOR REFERENCE ONLY

**FOR INFORMATION ONLY:  
DO NOT MANUFACTURE  
PARTS TO THIS DRAWING**

 Edmund Optics®			
THIRD ANGLE PROJECTION 		TITLE	4.45 x 2.20mm, 3.200 ROC, 750µm Pitch, Silicon, 1 x 4 Linear Microlens Array
ALL DIMS IN	mm	DWG NO	21178
			SHEET 1 OF 1